

Supplemental Material

Insights on the electronic structure of Tin (II) pyrochlore oxides with $5s^2$ lone pair states as transparent p-type oxide semiconductors

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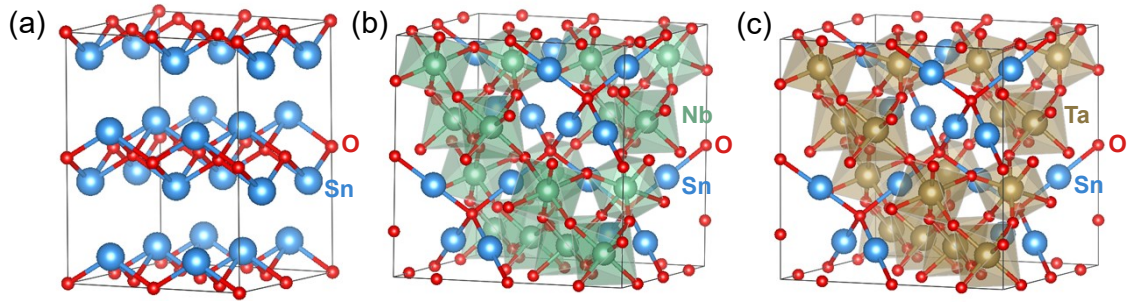


Figure S1. The crystal structure (a) litharge SnO; (b) pyrochlore $\text{Sn}_2\text{Nb}_2\text{O}_7$ and (c) pyrochlore $\text{Sn}_2\text{Ta}_2\text{O}_7$.

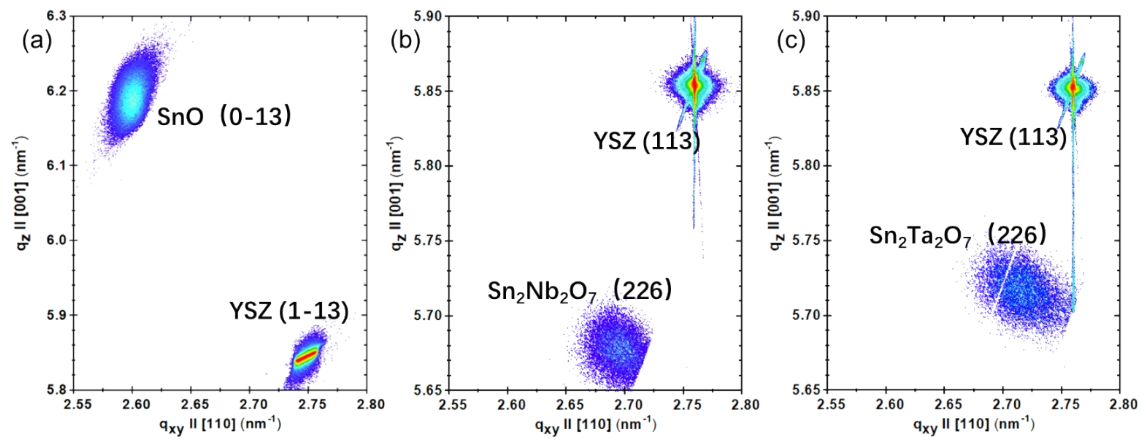


Figure S2. Reciprocal space mapping (RSM) of (a) SnO, (b) $\text{Sn}_2\text{Nb}_2\text{O}_7$ and (c) $\text{Sn}_2\text{Ta}_2\text{O}_7$ thin films grown on YSZ (001) substrate.

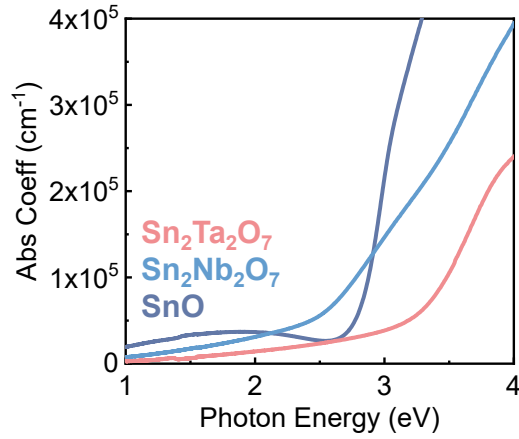


Figure S3. The optical absorption coefficient spectra of SnO, Sn₂Nb₂O₇ and Sn₂Ta₂O₇ thin films.

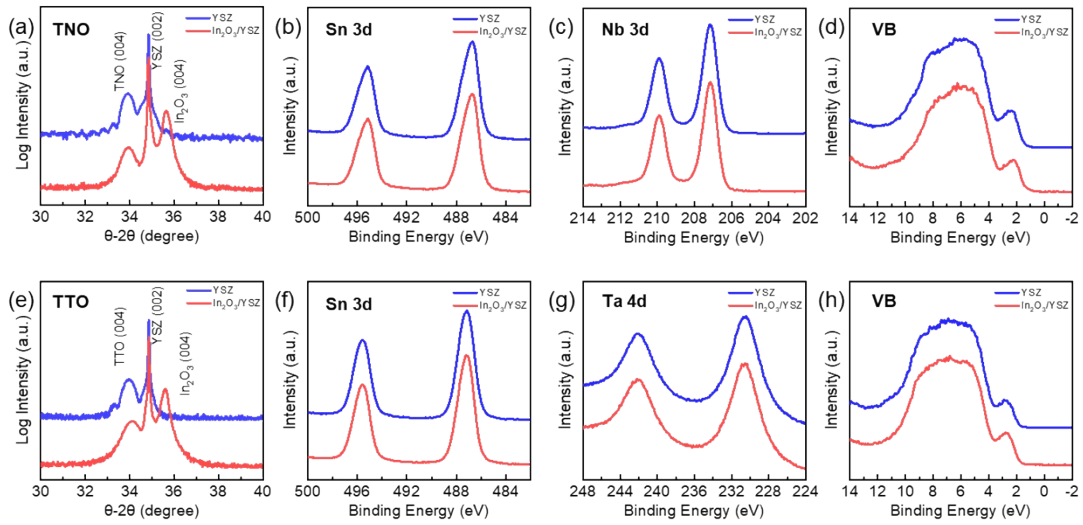


Figure S4. (a) X-ray diffraction (XRD) of Sn₂Nb₂O₇ (TNO) grown on YSZ (001) and In₂O₃ thin film coated YSZ(001) substrates; (b) Sn 3d_{5/2}, (c) Nb 3d and (d) VB XPS spectra of TNO thin films excited with photon energy of 1486 eV; (e) X-ray diffraction (XRD) of Sn₂Ta₂O₇ (TTO) grown on YSZ (001) and In₂O₃ thin film coated YSZ (001) substrates; (b) Sn 3d_{5/2}, (c) Nb 3d and (d) VB XPS spectra of TTO thin films excited with photon energy of 1486 eV.

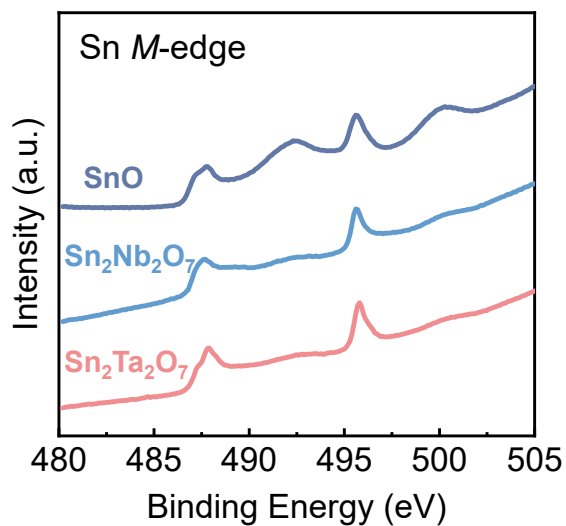


Figure S5. Sn M-edge XAS of SnO, Sn₂Nb₂O₇ and Sn₂Ta₂O₇.

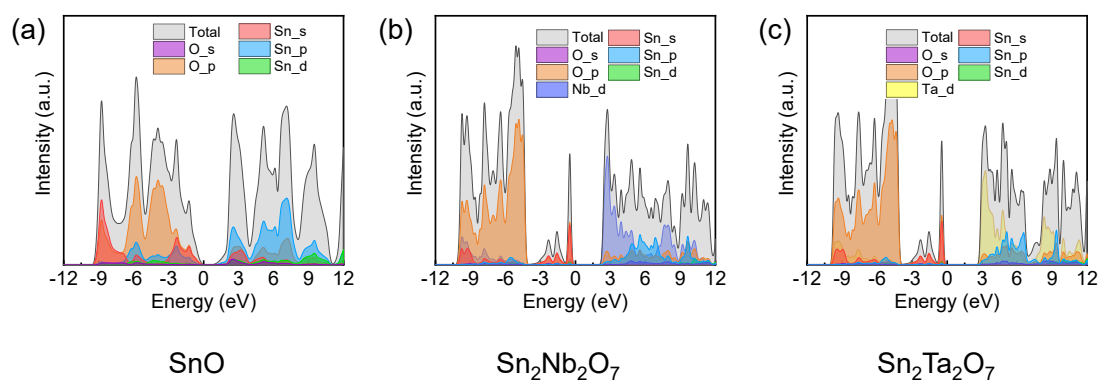


Figure S6. HSE06 calculated DOSs for (a) SnO, (b) Sn₂Nb₂O₇ and (c) Sn₂Ta₂O₇ from -12 eV to 12 eV.

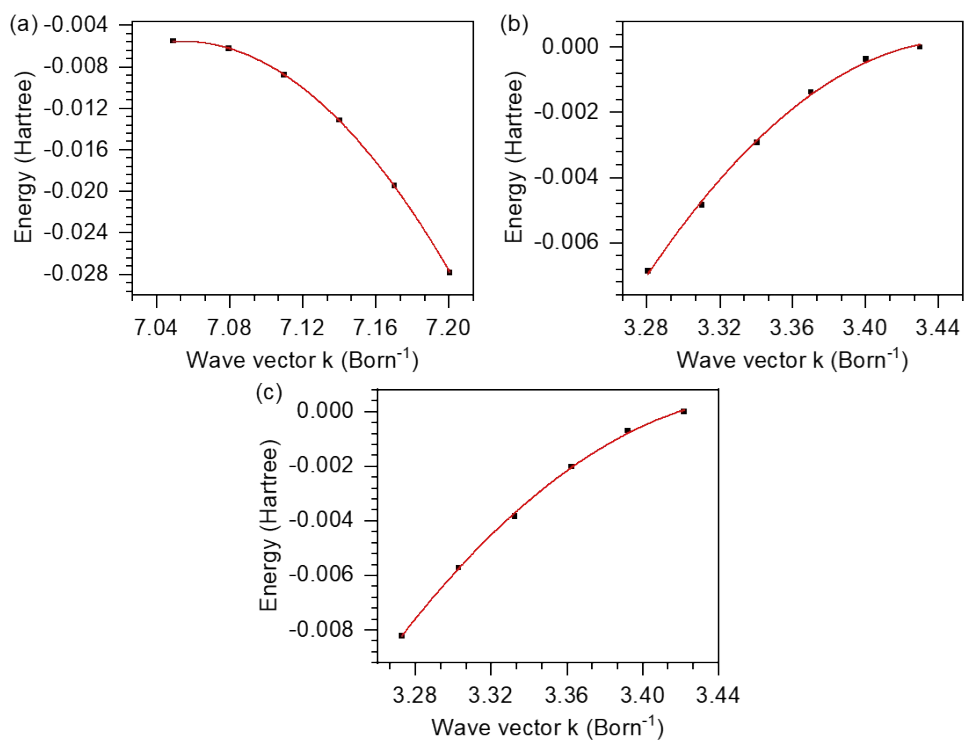


Figure S7. The parabolic fitting of hole effective mass at valence band maximum of (a) SnO; (b) Sn₂Nb₂O₇; (c) Sn₂Ta₂O₇.

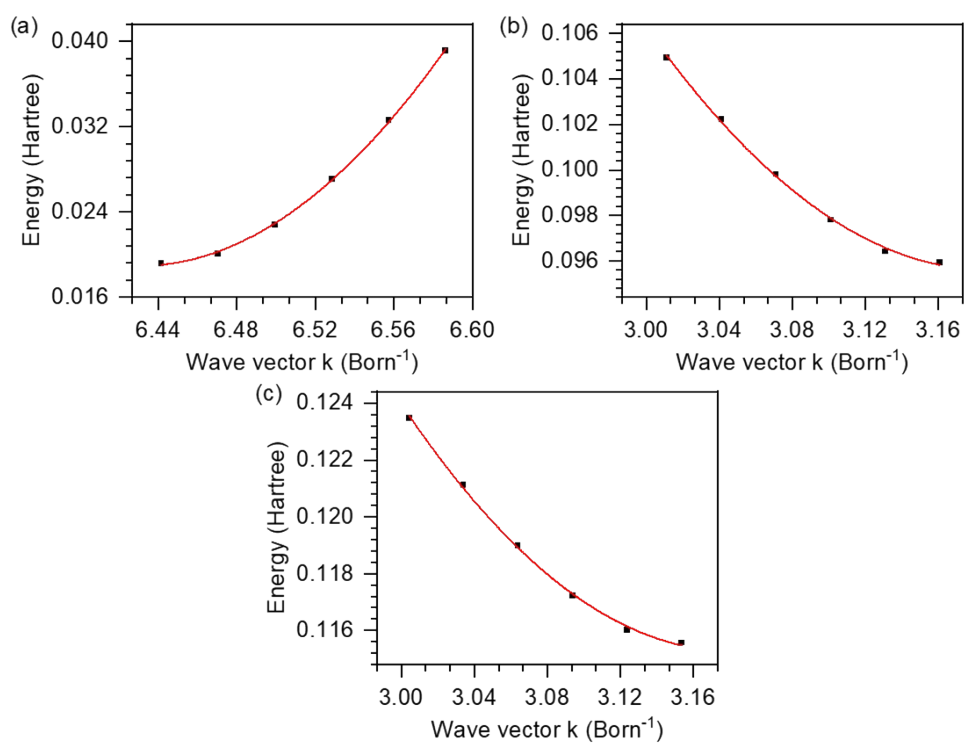


Figure S8. The parabolic fitting of electron effective mass at valence band maximum of (a) SnO; (b) Sn₂Nb₂O₇; (c) Sn₂Ta₂O₇.

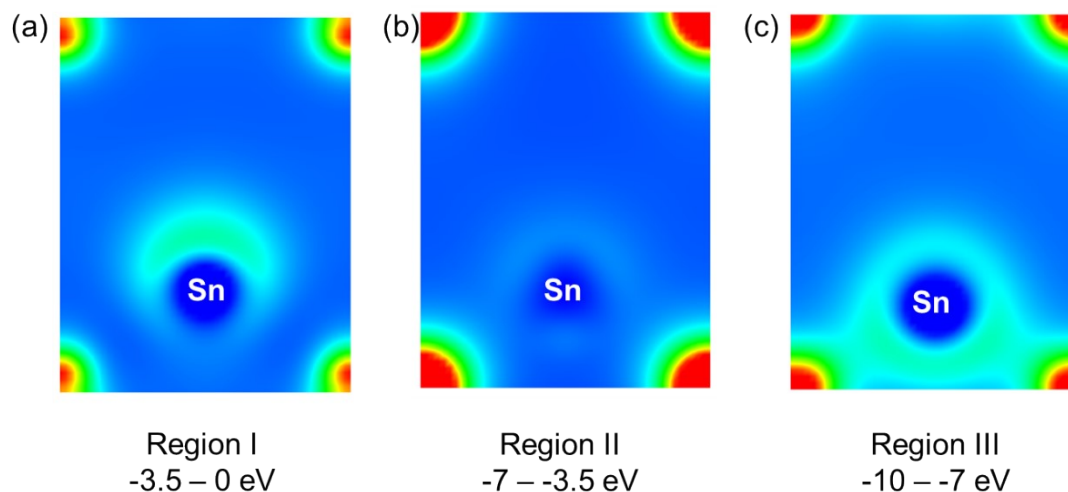


Figure S9. Partial electron density contour plots for litharge SnO. (a) -3.5 to 0 eV; (b) -7 to -3.5 eV (c) -10 to -7 eV.

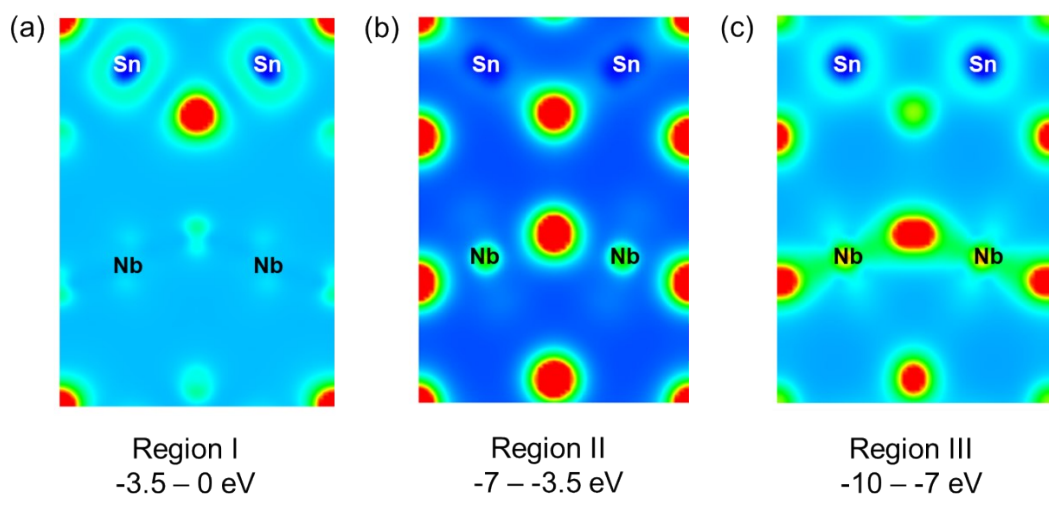


Figure S10. Partial electron density contour plots for pyrochlore $\text{Sn}_2\text{Nb}_2\text{O}_7$. (a) -3.5 to 0 eV; (b) -7 to -3.5 eV (c) -10 to -7 eV.

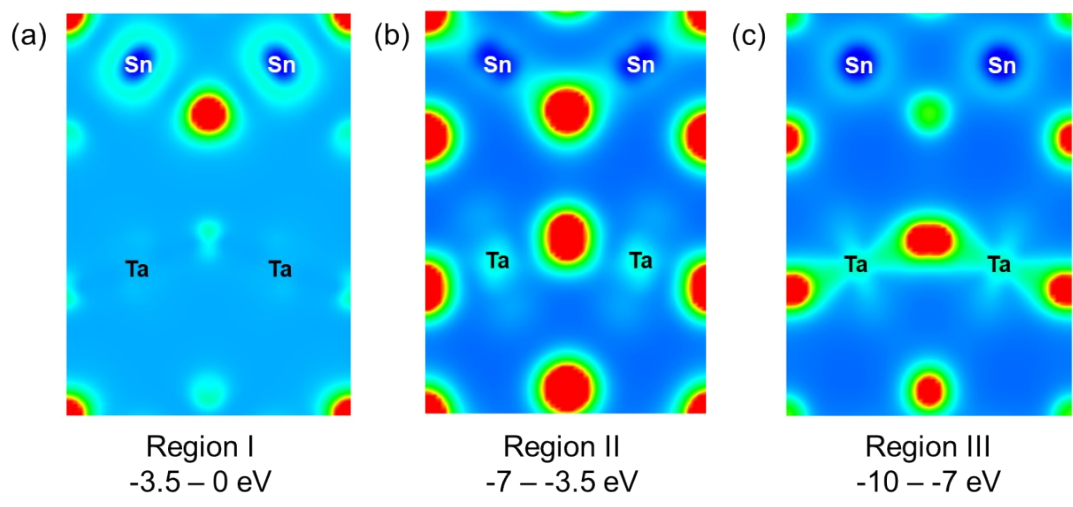


Figure S11. Partial electron density contour plots for pyrochlore $\text{Sn}_2\text{Ta}_2\text{O}_7$. (a) -3.5 to 0 eV; (b) -7 to -3.5 eV (c) -10 to -7 eV.

Table S1 The parabolic fitting parameters of hole effective mass

Materials	Quadratic coefficient (C) of fitting	term C of	Hole effective mass $\frac{1}{2C} / m_{hole}^*$	R-square (R ²) of fitting	Direction
SnO (Tetragonal)	-1.008±0.013		0.496	0.9999	Γ-Z
Sn₂Nb₂O₇	-0.239±0.026		2.092	0.9983	Γ-L
Sn₂Ta₂O₇	-0.224±0.019		2.232	0.9993	Γ-L

Table S2 The parabolic fitting parameters of electron effective mass

Materials	Quadratic coefficient (C) of fitting	term C of	Electron effective mass $\frac{1}{2C} / m_{elec}^*$	R-square (R ²) of fitting	Direction
SnO (Tetragonal)	0.624±0.098		0.801	0.9991	Γ-M
Sn₂Nb₂O₇	0.301±0.028		1.661	0.9988	Γ-K
Sn₂Ta₂O₇	0.265±0.026		1.887	0.9988	Γ-K

Table S3. Comparison of lattice parameters of epitaxial SnO, Sn₂Nb₂O₇ and Sn₂Ta₂O₇ thin films with their bulk values.

Materials	In-Plane (Å)	Out-of-Plane (Å)	Bulk values (Å)
SnO (Tetragonal)	a=3.84	c=4.85	a=3.80, c=4.84
Sn ₂ Nb ₂ O ₇	a=10.49	a=10.57	a=10.58
Sn ₂ Ta ₂ O ₇	a=10.42	a=10.49	a=10.48

Table S4. The parabolic fitted effective mass of electrons and holes at different k-points in the Brillion zone for SnO, Sn₂Nb₂O₇ and Sn₂Ta₂O₇. The directions of the carriers' movement are also listed behind the effective mass value.

Material		Effective mass / m_e	Direction
SnO	Electron	0.80	M- Γ
	Hole	0.50	Γ -Z
Sn ₂ Nb ₂ O ₇	Electron	1.66	Γ -K
	Hole	2.09	L- Γ
Sn ₂ Ta ₂ O ₇	Electron	1.89	Γ -K
	Hole	2.23	L- Γ